Supporting Information

Humic acid removal by gas-liquid interface discharge plasma:

performance, mechanism and comparison to ozonation

Yanyan Cui^{a, b}, Jianwei Yu^{a, d*}, Ming Su^{a,d}, Zeyu Jia^{a,d}, Tingting Liu^{a,d}, Gaku Oinuma^c, Tokiko Yamauchi^c

^a Key Laboratory of Drinking Water Science and Technology, Research Center for Eco-Environmental Sciences, Chinese Academy of Sciences, Beijing, 100085, China;

^b China university of Mining & Technology, Beijing, 100083, China;

^cAdvanced Technology R&D Center, Mitsubishi Electric Corporation, Hyogo, Japan;

^d University of Chinese Academy of Sciences, Beijing 100049, China.

Corresponding Author:

Jianwei Yu, Tel: 86-10-62849149; Fax: 86-10-62923541; E-mail: jwyu@rcees.ac.cn

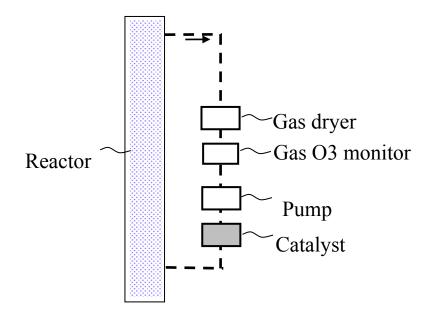
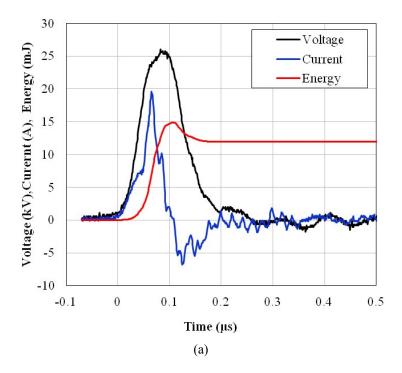


Fig. S1 Schematic diagram of the experimental apparatus with ozone decomposing catalyst



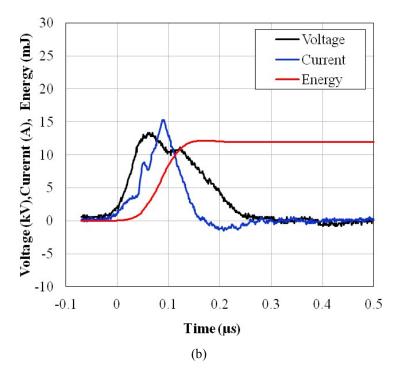
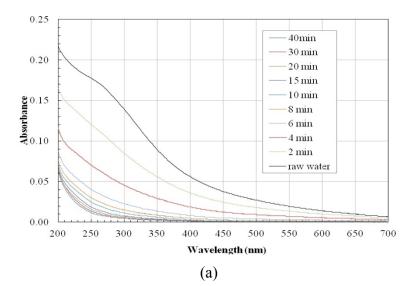


Fig. S2 Typical waveforms of pulse voltage, discharge current, and discharge energy in the pure carrier gas of (a) O₂ and (b) Ar (discharge conditions: 500pps, 12mj/pulse, 6W)



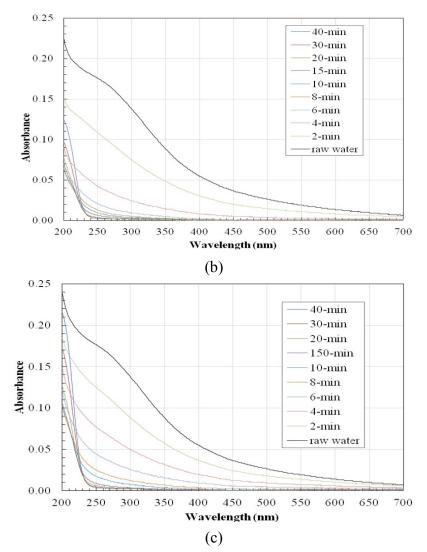


Fig.S3 UV/Vis absorbance of HA during ozonatin treatment (a) and plasma without catalyst (b) and with catalyst (c)